

| | Hits | Search Text | DBs |
|----|------|--|--|
| 22 | 23 | ((under or bottom or conductive or metal\$4 or dielectric) near14 (deposit\$4 or form\$3 or layer or film or coat\$3)) and ((photoresist or resist or photo\$4cur\$4 or photo\$3imageable) same (novolac or epoxy or resin\$3 or \$5hydroxystyrene) same (photoactive or PAC or non\$6chemical\$5active or non\$6chemical\$8amplif\$8) same (expos\$4 or illuminat\$4 or irradiat\$4) same pattern\$4) and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) and \$6hydroxystyrene | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 23 | 5 | (non\$5chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) and polyhydroxystyrene | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |

| | Hits | Search Text | DBs |
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| 24 | 6 | (non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and photo\$3active and develop\$4 and (solubilization or \$3solubilizing or soluble or solubility or insoluble) and polyhydroxystyrene | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 25 | 5 | (non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and photo\$3active and develop\$4 and poly\$4hydroxystyrene | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 26 | 6 | (non\$2chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$2active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |

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|----|------|---|--|
| 27 | 10 | (non\$5chemical\$5 near9 (amplification or amplify or amplified)) and (chemical\$4 near12 (amplification or amplify or amplified)) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4 and ((solubilization or \$3solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 28 | 6 | ((("6444408") or ("6340734") or ("6087064") or ("5385804") or ("5338818") or ("5985524"))).PN. | US-PGPUB; USPAT |
| 29 | 15 | ((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (resist or photoresist or photosensitive) and resin\$4 and photo\$4active and develop\$4 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 30 | 1 | ((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (photoactive near26 phenyl) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 31 | 1 | ((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified))) and (photoactive same phenyl) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |

| | Hits | Search Text | DBs |
|----|------|--|--|
| 32 | 66 | ((non\$3chemical\$5 near9 (amplification or amplify or amplified)) same (chemical\$4 near12 (amplification or amplify or amplified)) same (modif\$6 or replac\$4 or displac\$4 or chang\$4 or using or use)) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |
| 33 | 60 | S36 NOT S33 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB |